

4<sup>th</sup> EIROforum School on Instrumentation



#### European The Science Instruments at XFEL.EU

#### Single Particles, Clusters and Biomolecules and Serial Femtosecond Crystallography **SPB** Structure determination of single particles: atomic clusters, bio-molecules, virus particles, and cells. MID Materials Imaging & Dynamics Structure determination of nano-devices and dynamics at the nanoscale. FXE Femtosecond X-ray Experiments Time-resolved investigations of the dynamics of solids, liquids, gases HED **High Energy Density Matter** Investigation of matter under extreme conditions using hard X-ray FEL radiation, e.g. probing dense plasmas SQS Small Quantum Systems 1E-50 Investigation of atoms, ions, molecules and 1E-52 (cm<sup>4</sup>.s)

1E-54 1E-56 XFE 1E-58 1E-60 20 25 30 35 40 48

6

Tuned XFEL pump selected transition in

Probe beam for Thoms catter gets T. and N



plume with mi dot targe

Hard X-Rays

Soft X-Rays

clusters in intense fields and non-linear phenomena

SCS Soft X-ray Coherent Scattering/Spectroscopy

Electronic and real structure, dynamics of nano-systems and of non-reproducible biological objects

# **XFEL** European XFEL Time Structure



The European XFEL unique features poses strict constraints on detectors.

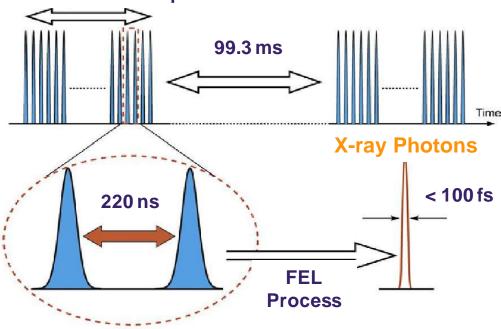
One of the main issues are the intensity and distinctive XFEL time structure.

Most of the time the use of commercial detectors is excluded.

Most applications require 4.5 MHz repetition rate detectors

e<sup>-</sup> Bunch and X-ray Pulse Structure e<sup>-</sup> Bunch Train



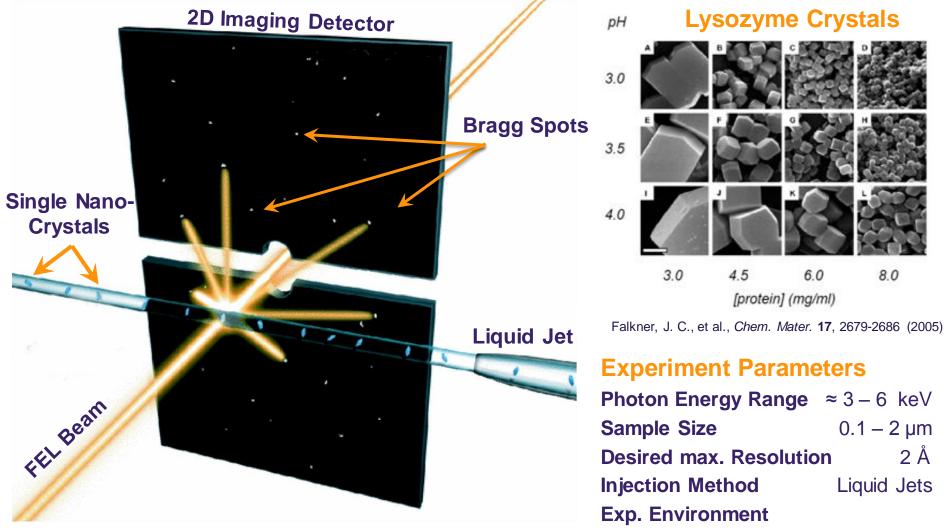


On average up to 27.000 pulses/s Pulse duration  $< 100 \, \text{fs}$ High peak intensities up to 10<sup>12</sup> photons/pulse Various different pulse patterns possible 1 pulse per train n pulses per train ... Linear, logarithmic or random dis-

tribution



#### European **SPB/SFX-I:** Serial Femtosecond Crystallography



After Lukas Lomb et al., Phys. Rev. B 84, 214111 (2011)

Vacuum  $10^{-4} - 10^{-6}$  mbar

6.0

2 Å

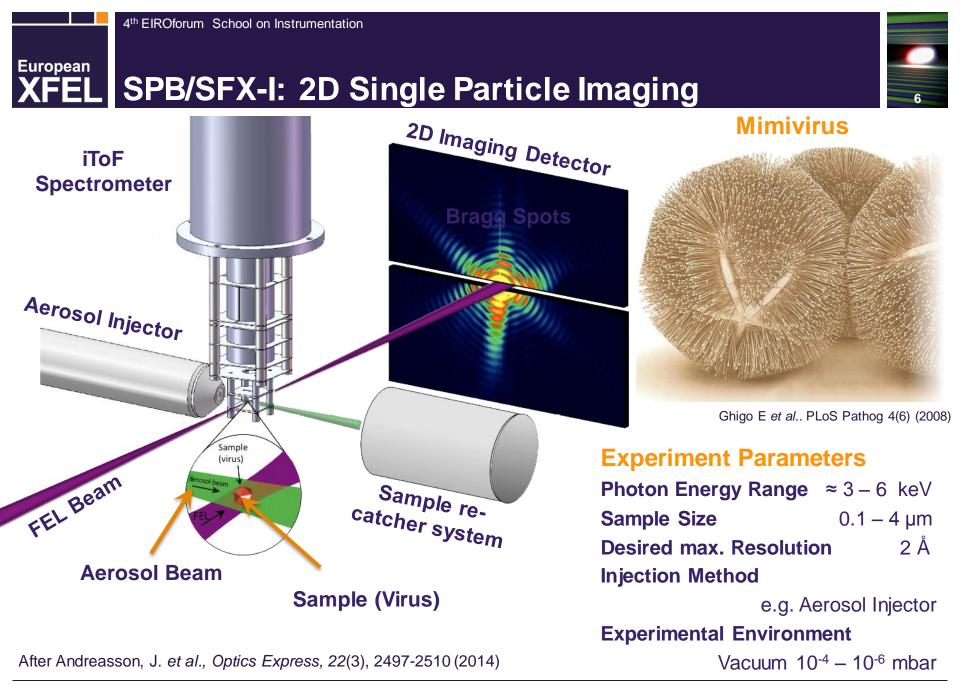
8.0

European SPB/SFX-I: Serial Femtosecond Crystallography XFEI Diffraction Image of a Single 'ery Bright **Diffraction Pattern Substructure Spots** 3 2 n nanocrystals 0 > 10<sup>4</sup> **Very Weak** -1 oh/pixel/pulse Signal 0, at least >5Kewish, et al. New J. of Phys. 12 (2010) 035005 Frame

Barty, A. et al. J. Appl. Cryst. (2014) 47, 1118-1131

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Integrated Bragg peak intensity + location

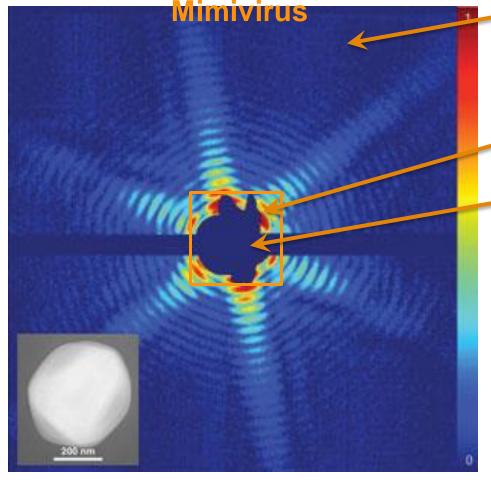


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# **XFEL** SPB/SFX-I: 2D Single Particle Imaging

#### **Diffraction Pattern of a**



Courtesy: J. Hajou

Single photon hits at high scattering angles

Very high intensity at central beam region

Hole for central FEL beam

#### **Experiment Parameters**

**Typical Samples** 

Biological organelles, small cells **Required #Images per Dataset** 1 **Signal level of interest at detector**  $1 - 10^8$  ph/pixel/pulse and higher

Required sampling points

per speckle

>4

Information extracted from single frame

Full diffraction pattern



# **XFEL** 2D Imaging Detector Requirements

#### **XFEL Pulse Structure**

Single pulse imaging Recoding 100 fs, readout 220 ns Storage of complete pulse train 2700 images

#### **Dynamic Range**

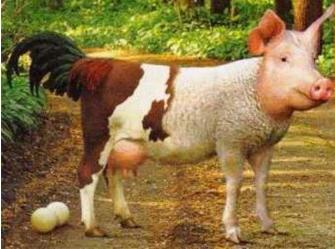
Single photon counting (high q/single particle scattering) Integration of up to 10<sup>5</sup> ph/pixel/pulse and more ...

#### **Sensitive Energy Range**

0.25 (SQS, SCS) – 25 keV (MID, HED)

Ideally with same detector Optimized entrance window for low photon energy





#### **Radiation Hardness**

Integrated energy dose over 3 years of operation

1 MGy – 1 GGy

Damage effects depend on energy range!

Graafsma, JINST 4 (2009) pp. 2011

#### **Angular Resolution**

7 mrad for FDE experiments 4 μrad for XPCS (worst case at 10 cm distance) Pixel size: 700 μm to 16 μm (XPCS at 4 m distance) Angular Coverage/ Sensor Size

fraction experiments require solution of 0.1 nm attering angles of 60° 20°)

Multiple detector segments Main Scientific Applications

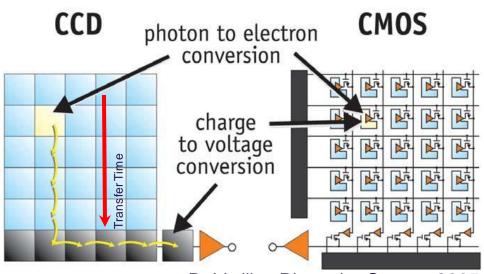
MID, SCS, FXE, SPB and SQS

Match the environmental conditions

Vacuum  $\iff$  Ambient operation



# XFEL Sensor Technology CMOS vs. CCD



D. Litviller, Photonics Spectra 2005

#### **Active Pixel Sensors (CMOS)**

- Fast readout up to MHz
- Reduced power consumption
- Various readout modes possible (any region on the sensor)
- Signal processing in pixel
- $\rightarrow$  storage, AD conversion, amplification

#### History

Both technologies developed in the late 1960s and early 1970s

Lithography limited at that time

- $\rightarrow$  CMOS performance limited
- $\rightarrow$  CCDs dominated the market

Situation changed when 250 nm, 180 nm, 130 nm processes became available

#### **Charge Coupled Device (CCD)**

Slow readout

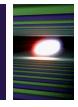
few Hz to approx. 100 kHz possible

Low noise

Radiation hard

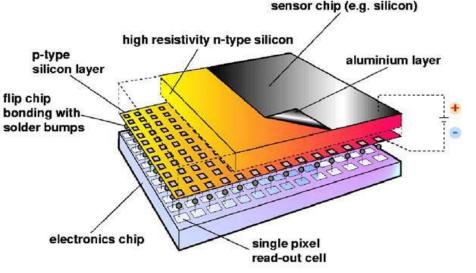
(e.g. pnCCD technology)

#### High fill factor



## XFEL Sensor Technology CMOS vs. CCD

#### Hybrid Pixel Sensor



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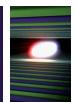
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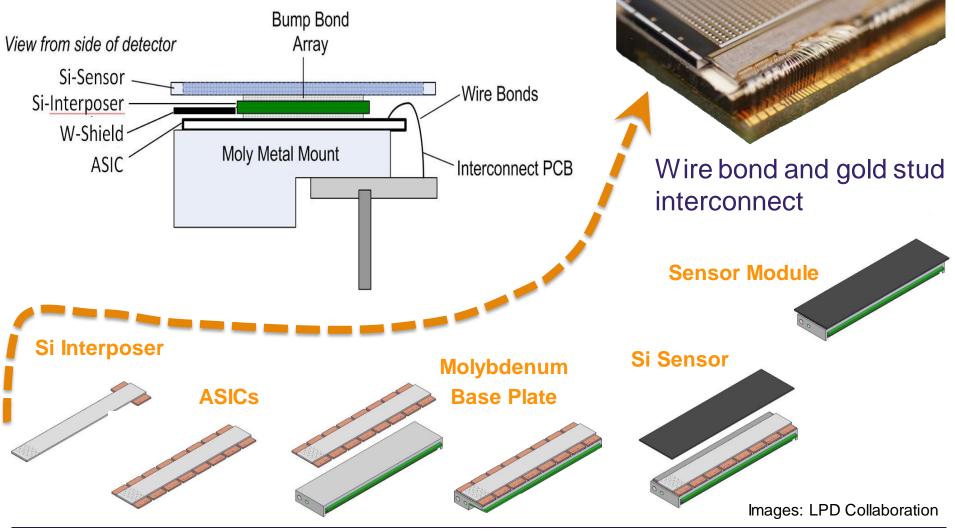
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#### High fill factor



# **XFEL** What Do You Need to Build a Sensor Module?

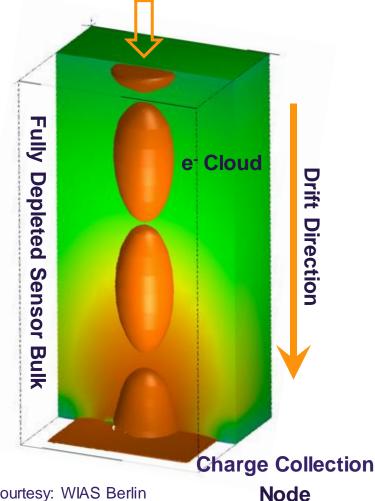
#### **Example LPD Sensor Module**





#### European Charge Transport in Silicon





Electron hole pair creation at interaction point mainly through photoelectric absorption.

Motion of charge carriers due to external electric field E and the resulting charge density gradient  $\frac{dn}{dx}$  leads to **Drift Current Density** 

$$\vec{J}_n = qn\mu_n \vec{E}$$

Electron density

 $\mathcal{M}_n$  Mobility

F Electric field

#### **Diffusion Current Density**

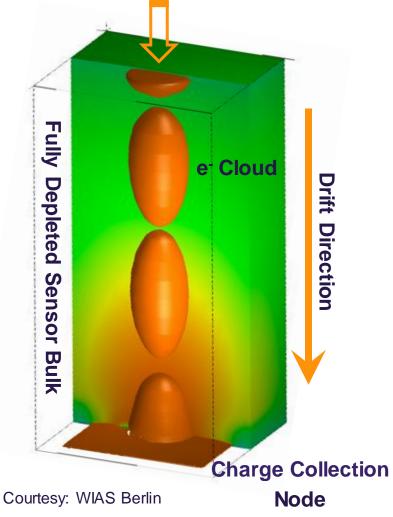
$$J_n = q D_n \frac{dn}{dx}$$

 $D_n$  Diffusion constant *dn* Electron density dx gradient Similar equations hold for holes, not shown here.

Courtesy: WIAS Berlin

# **XFEL** Charge Transport in Silicon





$$\vec{v} = -\mu_n \cdot \vec{E}$$

**Drift Velocity** 

**Mobility** 

$$\mathcal{M}_n = \frac{et_n}{\mathcal{M}_n}$$

 $\vec{E}$  Electric field  $\mathcal{M}_n$  Mobility

- *e* Electron charge
- *t*<sup>n</sup> Mean free time between collisions *m*<sup>n</sup> Eff. Mass of

Typical values for Si at 300 K electrons

 $M_n \gg 1450 cm^2 / Vs$   $M_p \gg 450 cm^2 / Vs$ 

S.M. Sze, Semiconductor Devices , J. Wiley & Sons, 1985

The local drift velocity only depends on the electric field in the depleted volume.

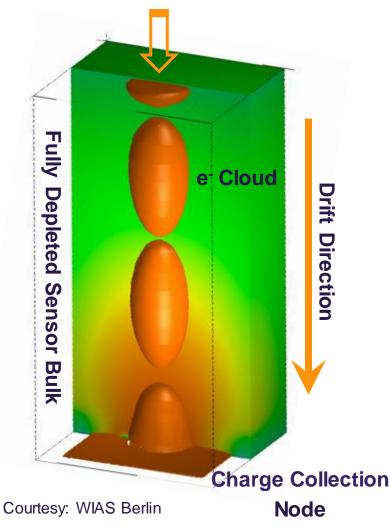
Drift velocity defines the time until the charges reach the readout node.

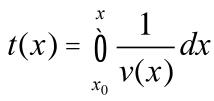


# **XFEL** Charge Collection Time









Typical values in n-type Si with a resistivity of 10  $k\Omega$  cm

t<sub>c,n</sub> ≈ 30 – 50 ns

Approximate size of the charge cloud

 $R_{el} \sqcup arphi^{-0.8} E_{el}^{1.3}$ 

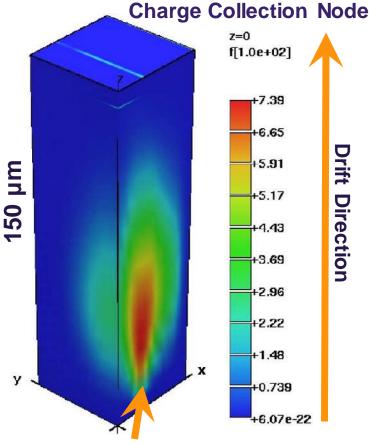
Typical values for a bias voltage of 300 V and 450  $\mu m$  thick fully depleted sensitive volume



# **XFEL** Charge Transport in Silicon



#### e<sup>-</sup> Charge Density



**Photon Interaction** 

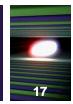
Strüder et al. NIM A (2010) vol. 614 pp. 483

#### Plasma Regime

- XFEL pulse duration < 100 fs
- $\rightarrow$  energy deposition is instantaneous
- At XFEL intensities electron hole pairs are not independent any more
- $\rightarrow$  plasma effects dominate
- Plasma is quasi neutral
- $\rightarrow$  Ambipolar diffusion dominates over
  - drift of charge carriers.

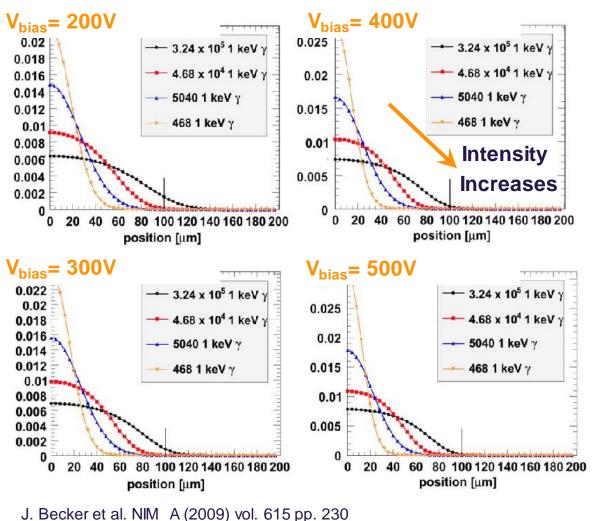
Effects dominate at high charge carrier densities, negligible at low charge carrier densities

- $\rightarrow$  influence on PSF/charge sharing
- $\rightarrow$  influence on charge collection time



# **XFEL** Charge Transport in Silicon – Plasma Regime

#### **1 keV Point Spread Function (I, V<sub>bias</sub>)**



#### **Parameter Dependance**

High intensity > 10<sup>3</sup> ph/pix/pulse

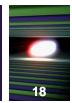
- $\rightarrow$  more electron hole pairs
- → diameter of the PSF increases

Higher photon energy

- $\rightarrow$  more electron hole pairs
- $\rightarrow$  diameter of the PSF increases

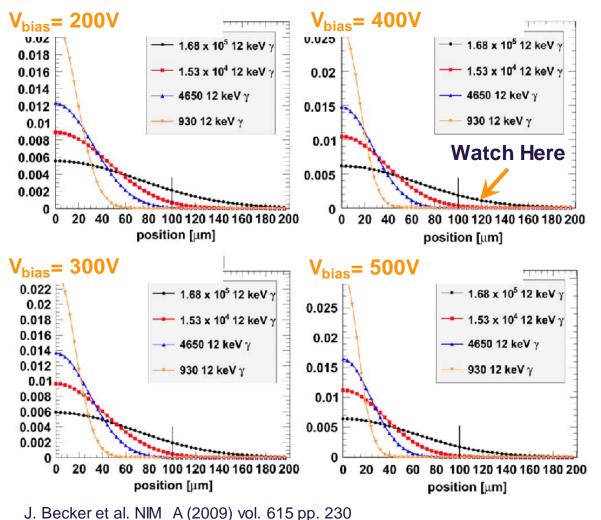
Higher bias voltage

- $\rightarrow$  stronger electric field
- $\rightarrow$  shorter drift time
- → diameter of the PSF decreases



# **XFEL** Charge Transport in Silicon – Plasma Regime

#### 12 keV Point Spread Function (I, V<sub>bias</sub>)



#### Parameter Dependance

High intensity > 10<sup>3</sup> ph/pix/pulse

- $\rightarrow$  more electron hole pairs
- → diameter of the PSF increases

Higher photon energy

- $\rightarrow$  more electron hole pairs
- $\rightarrow$  diameter of the PSF increases

Higher bias voltage

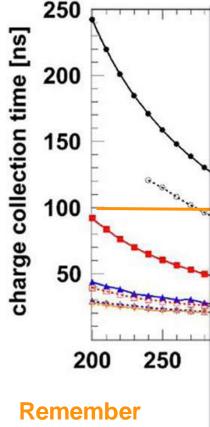
- $\rightarrow$  stronger electric field
- $\rightarrow$  shorter drift time
- → diameter of the PSF decreases



# **XFEL** Charge Transport in Silicon – Plasma Regime

#### **Charge Collection Time**

# Parameter Dependance



Due to XFEL time st

Conclusions	nh/niv/nuleo
$\rightarrow$ At photon intensities > the spatial resolution is	dominated by
plasma effects not by th	e pixel size

#### → Charge collection time is significantly longer in comparison to low intensity regime

→ For pixel sizes > 200 x 200 µm<sup>2</sup> ob served effects are not critical, fine tuning is possible
time

 $t_{collection} + t_{amplification} + t_{storeage} = 220 \text{ ns}$ 

J. Becker et al. NIM A (2009) vol. 615 pp. 230

decreases

# European



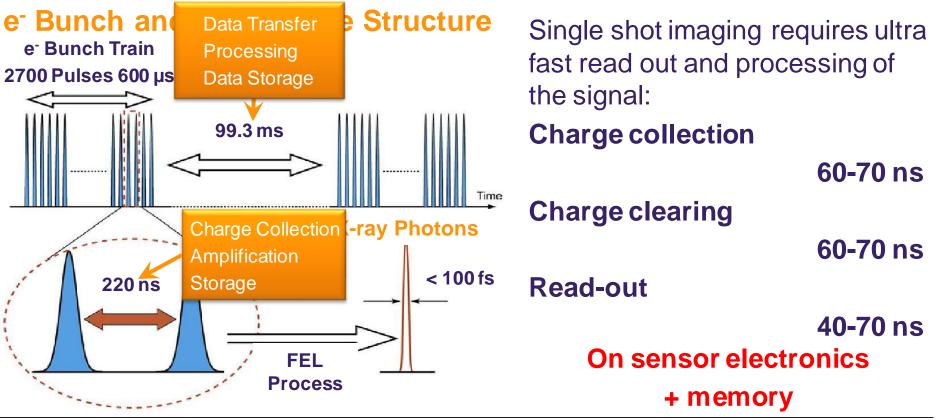


The European XFEL unique features poses strict constraints on detectors.

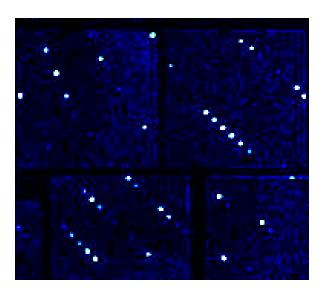
One of the main issues are the intensity and distinctive XFEL time structure.

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Ability of a detector system to record simultaneously very low signals alongside very intense signals.

$$D = \frac{S_{\max}}{S_{Tot}}$$

1

 $S_{\max}$  Maximum detectable signal

STot Total noise

Noise performance determines dynamic range at low intensities and full well capacity at high intensities.

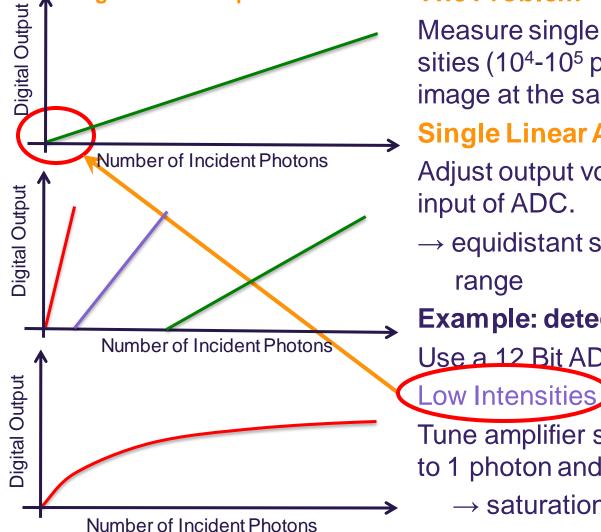
#### **Typical Values**

Detector	Full Well Capacity [e <sup>-</sup> ]	Read Noise [e <sup>-</sup> ]	Dynamic Range
Human Eye			10 <sup>2</sup> (stat) 10 <sup>14</sup> (dyn)
Modern CCDs	30.000-500.000	2 – 25	≈1.000 – 50.000









Measure single photons and high intensities (10<sup>4</sup>-10<sup>5</sup> ph/pixel/pulse) in the same image at the same time (no averaging).

#### Single Linear Amplifier + ADC

Adjust output voltage range of amplifier to input of ADC.

 $\rightarrow$  equidistant sampling of whole dynamic

range

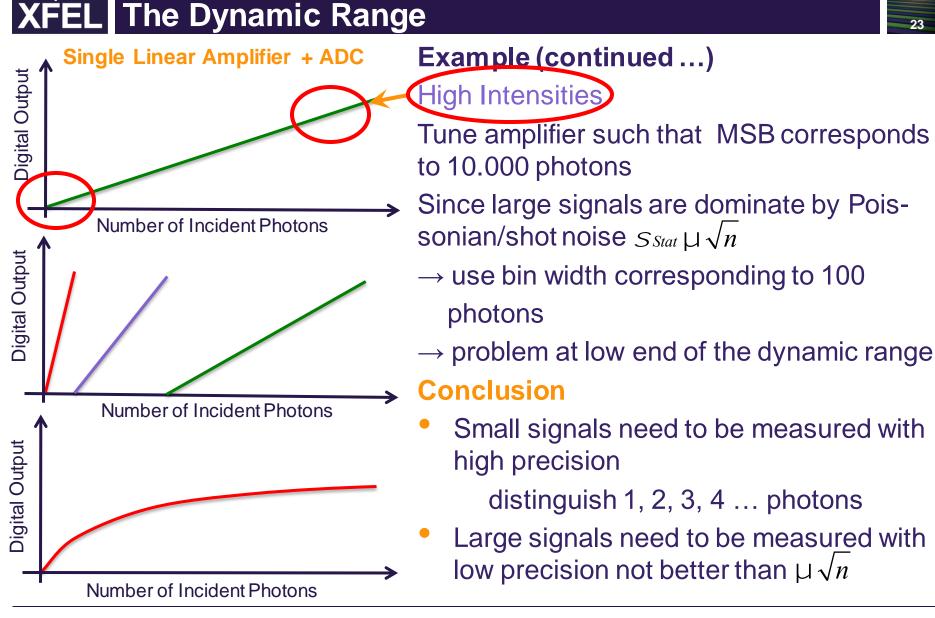
Example: detect 1 and 10.000 photons

Use a 12 Bit ADC  $\rightarrow$  4096 sampling steps

Tune amplifier such that LSB corresponds to 1 photon and bin width = 1 photon

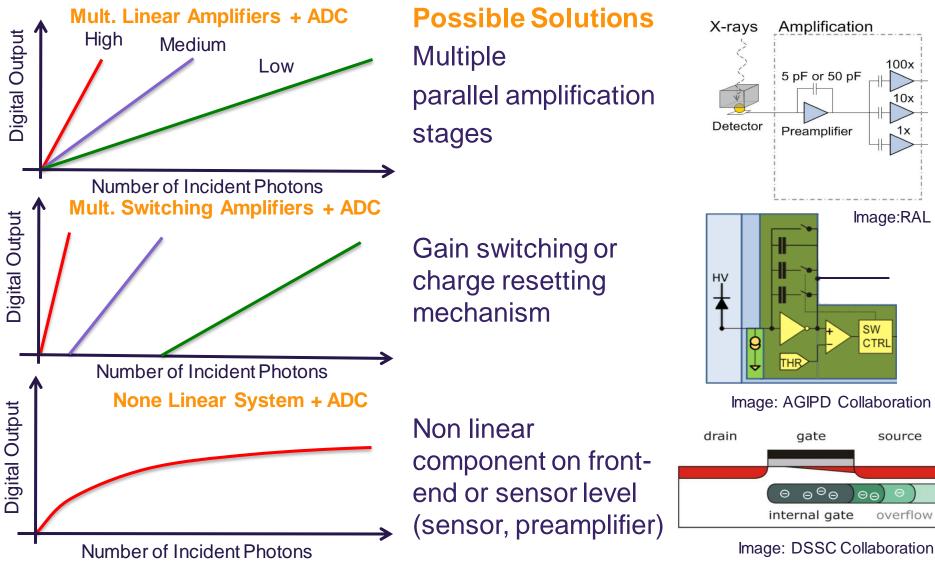
 $\rightarrow$  saturation at max. of 4096 photons





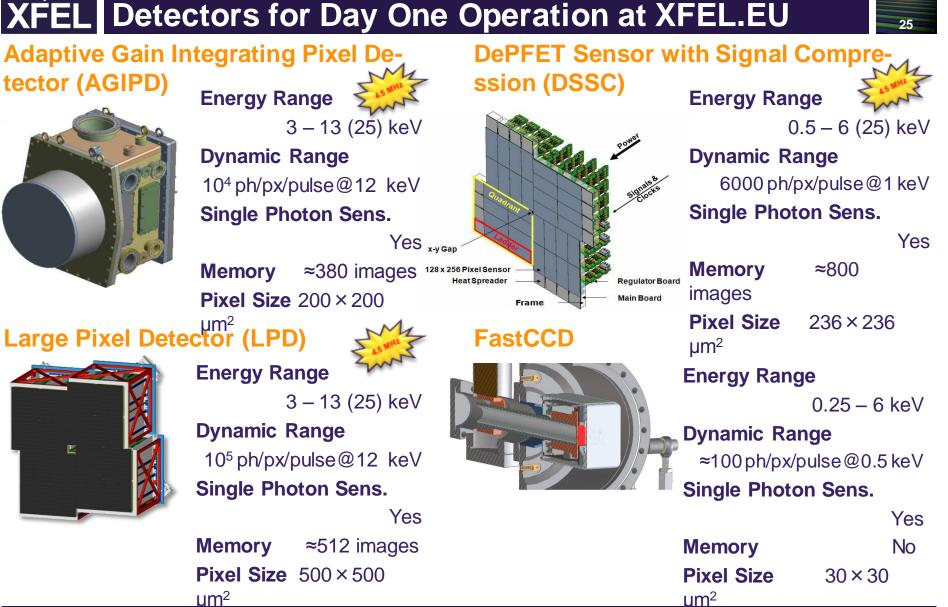
European

# XFEL The Dynamic Range

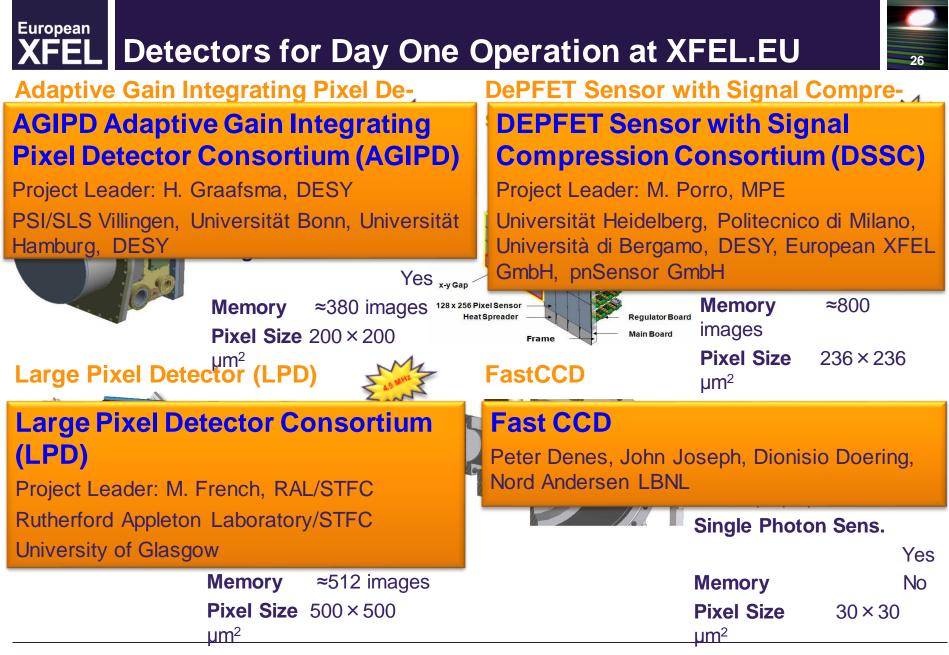


24



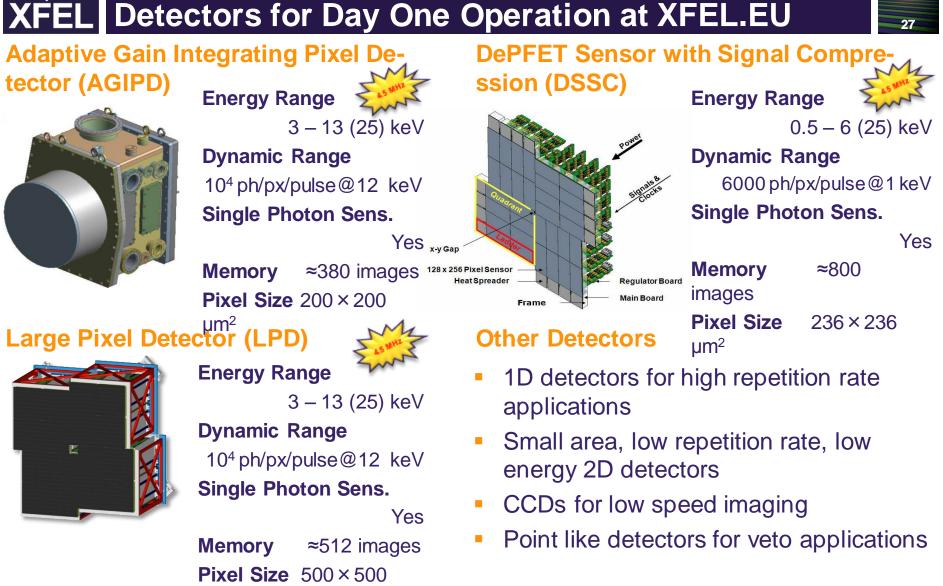


European

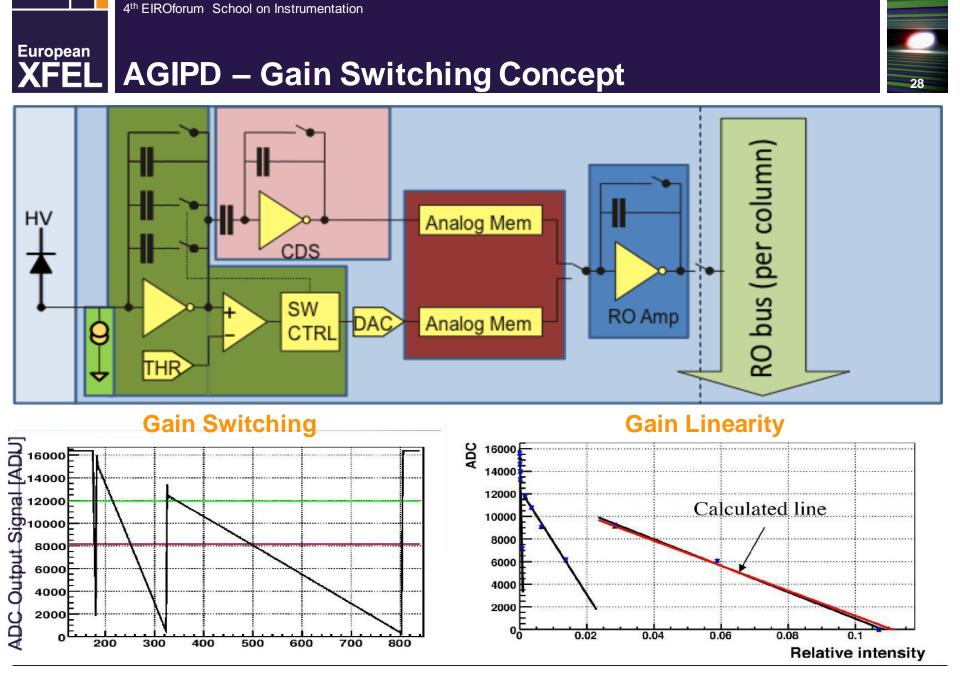


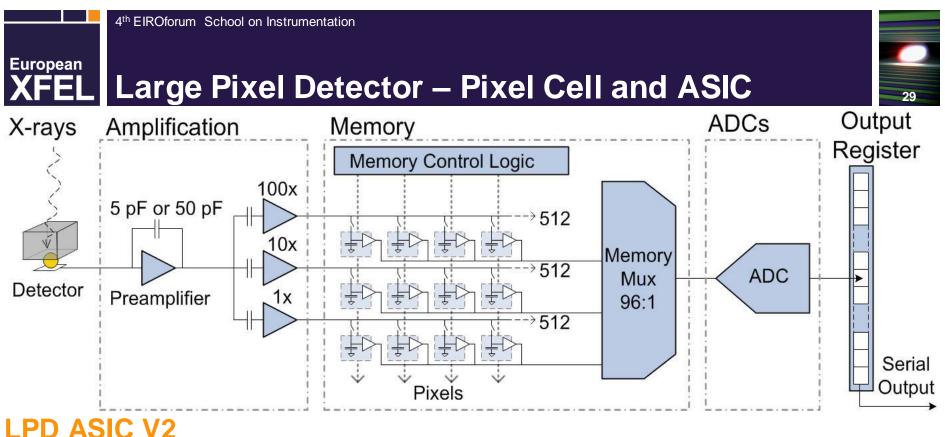
<u>um<sup>2</sup></u>



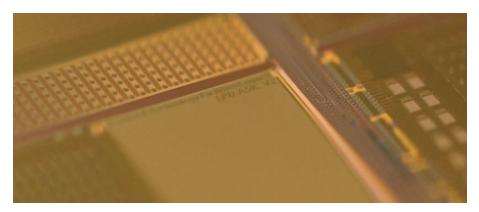


European





- Adjustable dynamic range
- 3 fold multi-gain concept and analog storage (1x,10x,100x)
- 512 images memory depth with veto (trigger)
- 16x 12 Bit on chip ADCs



Images: LPD Collaboration

June 18<sup>th</sup> 2015

Detectors for the European XFEL

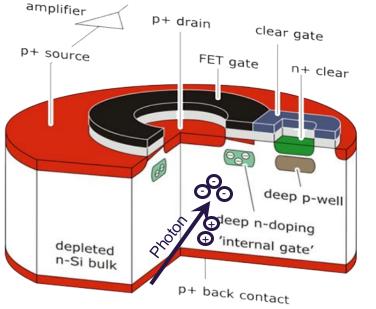
Markus Kuster

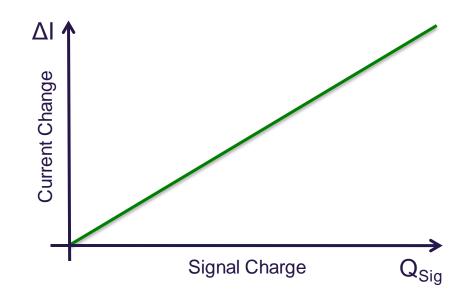


# **XFEL** Standard DePFET without Signal Compression

#### **DePFET Working Principle**

#### Linear System Response





J. Kemmer G. Lutz, NIM A. 253, Nr. 3,1987

Source drain current is steered by the amount of free charge carriers in the external gate Incident photon produces electron hole pairs Electrons drift to potential minimum at internal gate, holes to back contract

Mirror charges created in external gate steer I<sub>SD</sub>

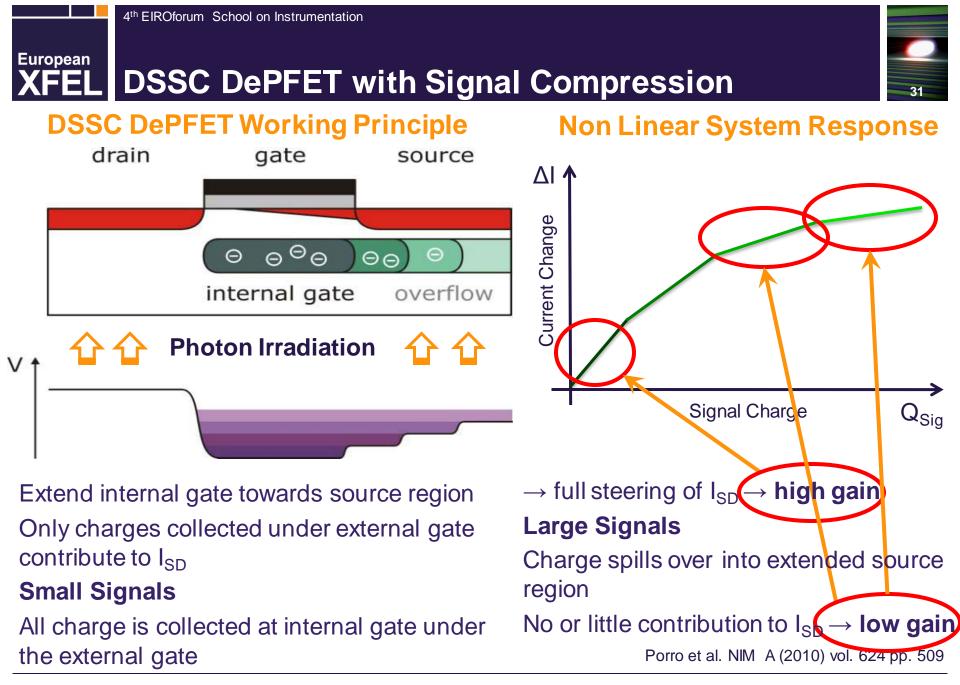
Measure  $I_{\text{SD}}$  which is proportional to the signal charge

Signal clearing is required to remove signal e<sup>-</sup> and e<sup>-</sup> from leakage current

#### **Advantages**

Low internal capacitance  $\rightarrow$  low noise

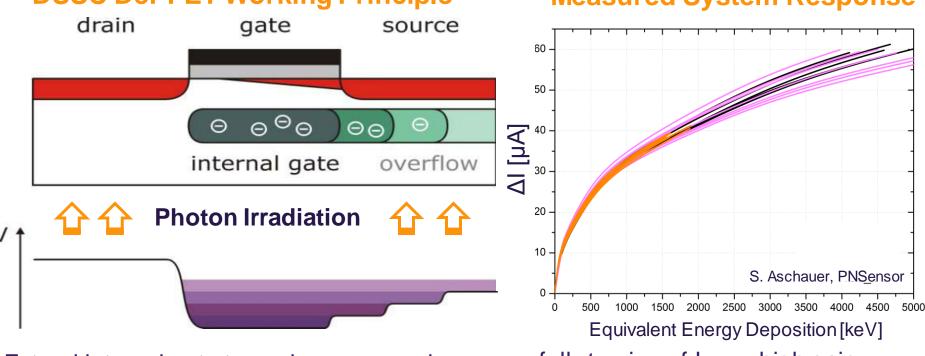
Non destructive measurement



June 18<sup>th</sup> 2015

Markus Kuster

# 4th EIROforum School on Instrumentation European XFEL DSSC DePFET with Signal Compression 32 DSSC DePFET Working Principle Measured System Response



Extend internal gate towards source region Only charges collected under external gate contribute to I<sub>SD</sub>

#### **Small Signals**

All charge is collected at internal gate under the external gate

 $\rightarrow$  full steering of I<sub>SD</sub>  $\rightarrow$  high gain

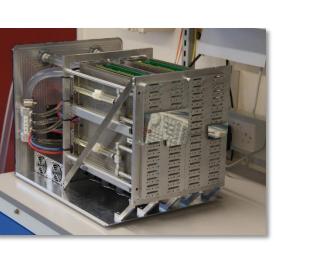
#### Large Signals

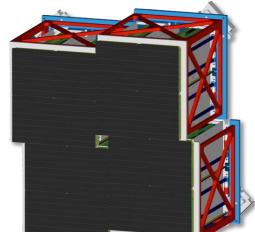
Charge spills over into extended source region

No or little contribution to  $I_{\text{SD}} \rightarrow$  low gain

Porro et al. NIM A (2010) vol. 624 pp. 509

# **XFEL LPD – Detector Systems**

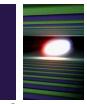




16 Super Modules 256 Detector Tiles 2048 ASICs

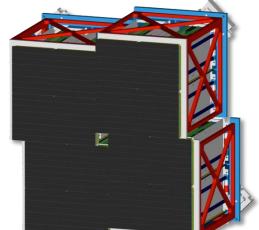
2-Tile System	1/4 Megapixel Detector	Megapixel Detector
Small flexible test system (32 x 256 pixels)	Test system at XFEL.EU (512 x 512 pixels)	Final system (1024 x 1024 Pixels)
Used for firmware tests, tests at beamlines, veto tests,	Temp. stabilized (water cooling) Connected to XFEL DAQ system	Movable Quadrants Currently under construction at STFC

# **XFEL LPD – Detector Systems**









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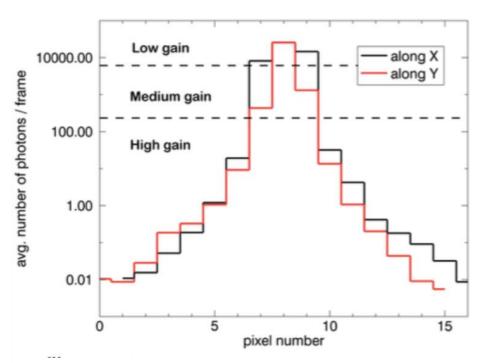
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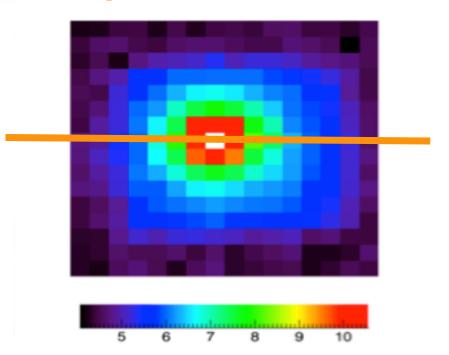


#### **EL** AGIPD – Direct Beam Measurements at PETRA III

#### **Intensity Distribution**



#### **Image of the Direct Beam**



Primary intensity 10<sup>4</sup> photons/pulse Single photon sensitivity Operated at 4.5 MHz

J. Becker et al. arXiv 1303.2502V1

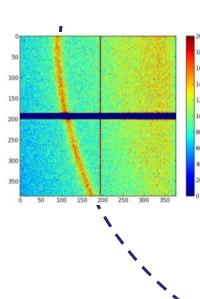




#### **XFEL** Large Pixel Detector – Performance

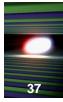
### **Diffraction Experiment at LCLS**

- at 9 keV
- Sample Titanium dioxide  $(TiO_2)$ on Kapton
- **Detectors**
- **CSPAD** and LPD Two Tile system



# **LPD Super Module**

36



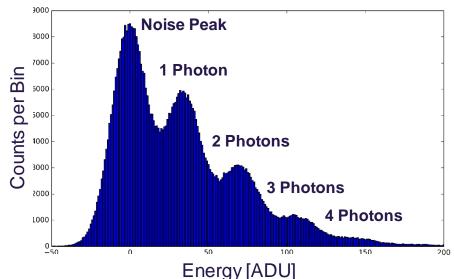
# **XFEL** Large Pixel Detector – Performance

# Performance tests at Diamond, LCLS, Petra III and in our Lab

Single photon sensitivity demonstrated down to 12 keV Noise 0.35 photons @ 12 keV

Tests with final hardware at ESRF and APS this fall

#### Photon Spectrum at 18 keV



#### Imaging and Charge Sharing **Properties** Column 175 150 (NDD) 125 100 100 Column 10 15 20 25 10 0 2 4 6 8 12 50 30 Row 20 40 60 120 0 80 100 Row

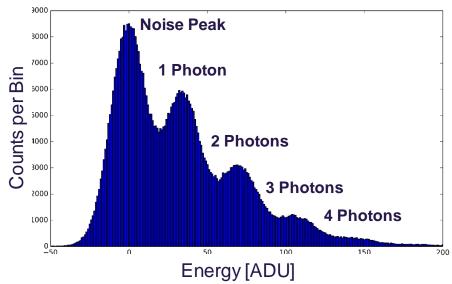


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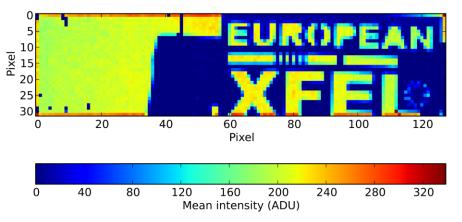
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### Photon Spectrum at 18 keV



### **Spatial Resolution**



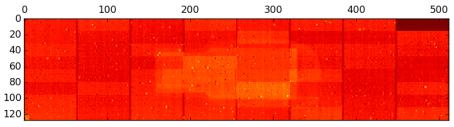


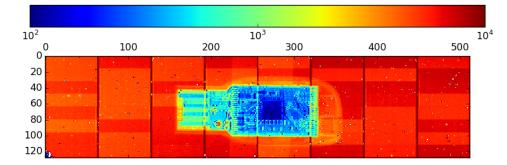


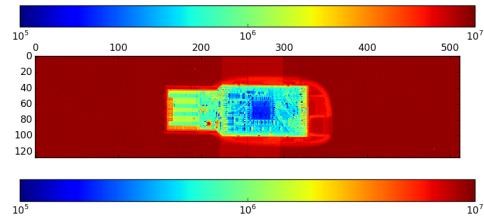
## **XFEL** Image Corrections – Example AGIPD

### X-ray of a Pen Drive

Mean of 10.000 images with an integration time of 50 µs



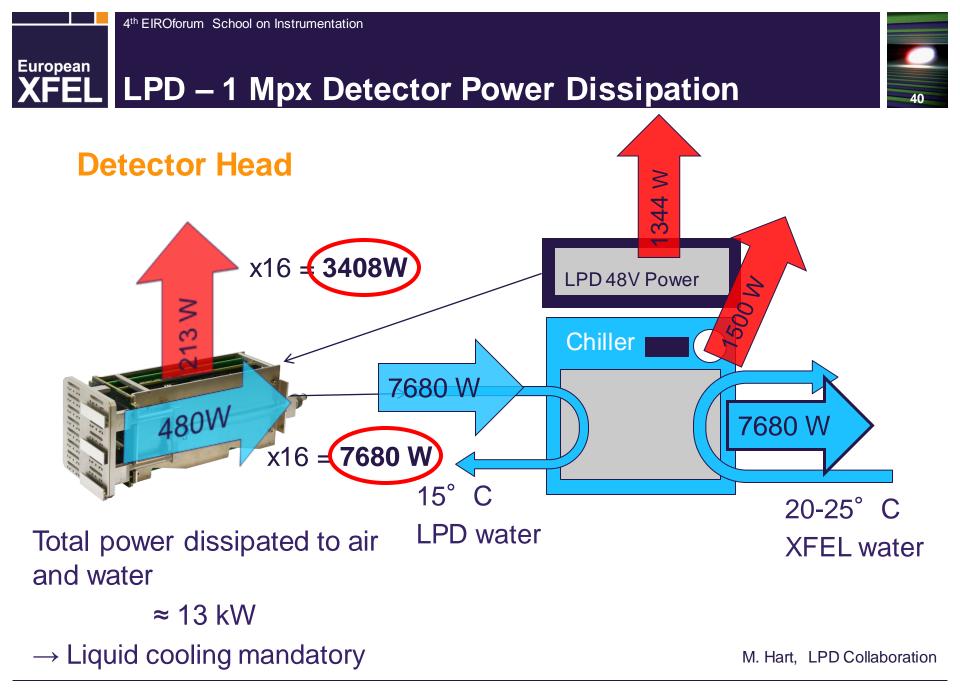




#### Intensity [Arbitrary Units]

### After dark field correction

After correcting for gain variation of different amplifiers



## EuropeanXFELExpected Data Rates

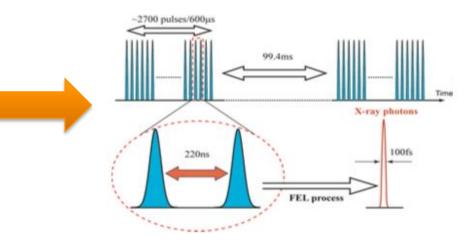
- Readout rate driven by bunch structure
  - 10 Hz train frequency
  - 4.5 MHz pulse frequency in trains
- Data rate driven by detector type

Detector type	Sampling	Data/pulse	Data/train	XFEL/sec	Future/sec
1 Mpxl 2D camera	4.5 MHz	~2 MB	~1 GB	~10 GB	~220 GB
1 channel digitizer	5 GS/s	~2 kB	~6 MB	~60 MB	~240 MB

### Challenges

- Gathering, calibrating and storing data of many detectors
- Data analysis, data reduction and processing
- Data long term storage and more ...

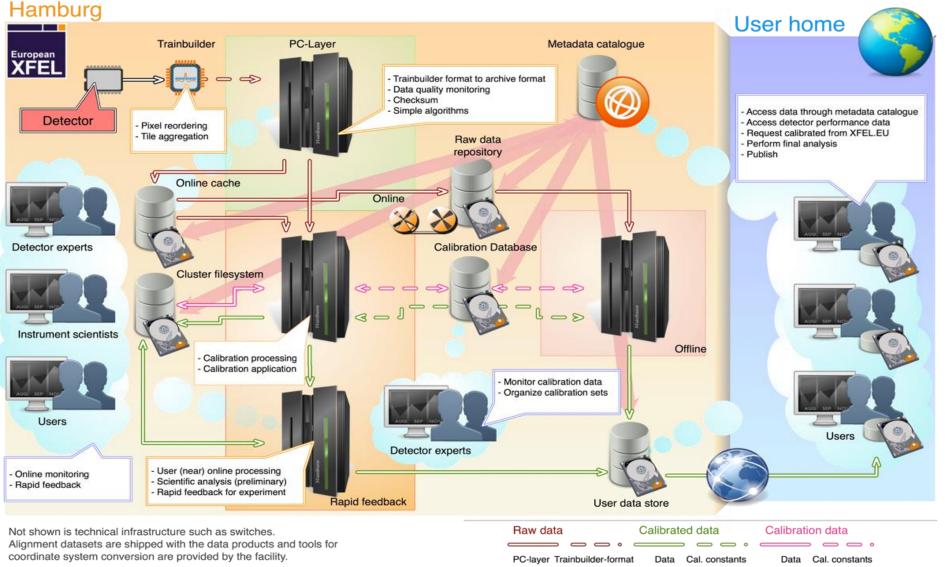
Day one 2016/17 10 PB offline disk storage.



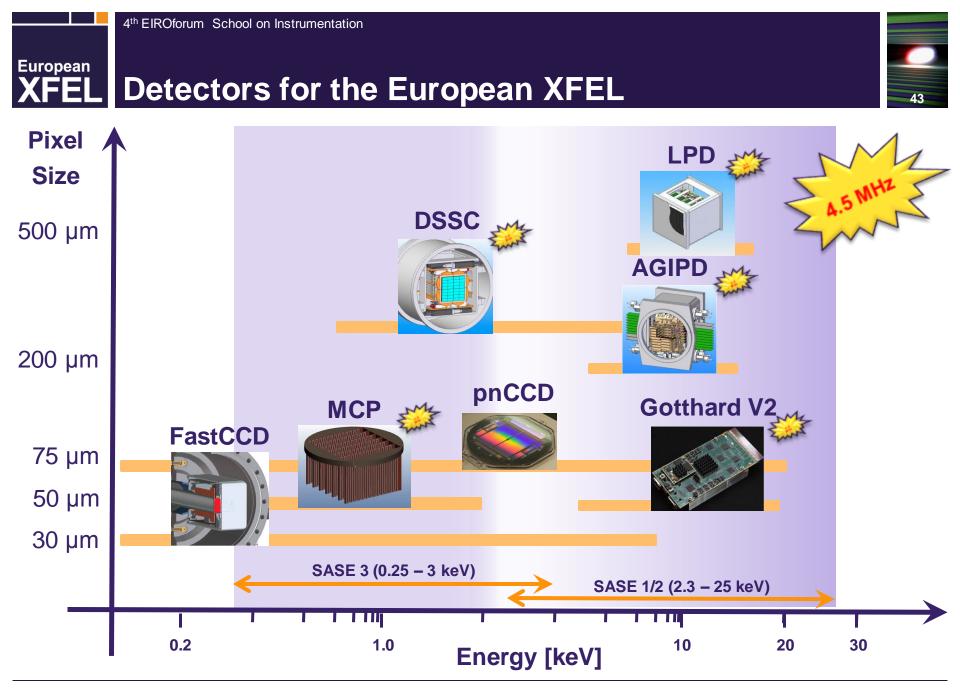


## **XFEL** Data Flow and Scientific Data Products

4<sup>th</sup> EIROforum School on Instrumentation



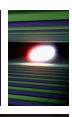
42



## **XFEL** Thank you for your attention!

There is a bright light at the end of the tunnel ... 2017 ...

... and we will see it ...



## **XFEL** Detector Group at the European XFEL

### Thank you for your attention!

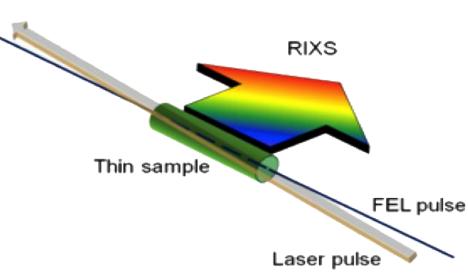
June 18th 2015

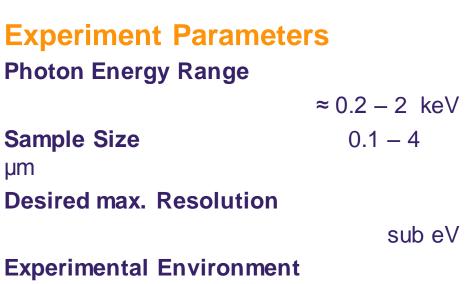


# European

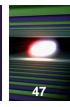
### FEL SQS: Resonant Inelastic X-Ray Scattering

- Excite sample with a short laser
- → probe sample with X-rays at after different times
- Study RIXS signal in two dimensions (dispersive/beam)
- → The time evolution of a pump laser excitation
- → Study emission from different positions along the sample (non-linear phenomena)
- Requires measurement of single photons in two dimensions at 4.5 MHz
- the dispersion direction (energy)
- the beam direction along the sample (position equivalent to time)





Vacuum  $10^{-6} - M_{Mus}^{-8} m_{har}$ 



## **XFEL** SQS: Soft X-ray Single Shot Spectrometer

### **Experiment Setup**

- Rowland geometry + detector at grazing incidence
- Wolter optics design allows magnification in the imaging direction by factor ≈ 8
- Two gratings to cover different energy ranges

### **Experiment Parameters**

**Required #Images per Dataset** 

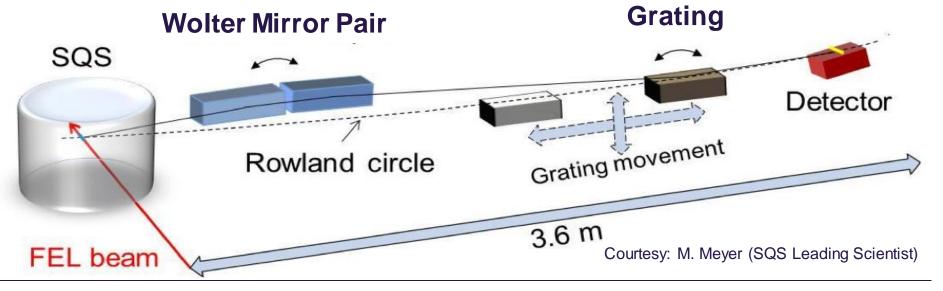
few tens

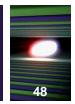
Signal level of interest at detector

 $1 - 10^2 \text{ ph/pulse}$ 

Information extracted from single frame

Full 2D spectrum

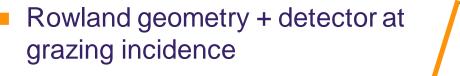




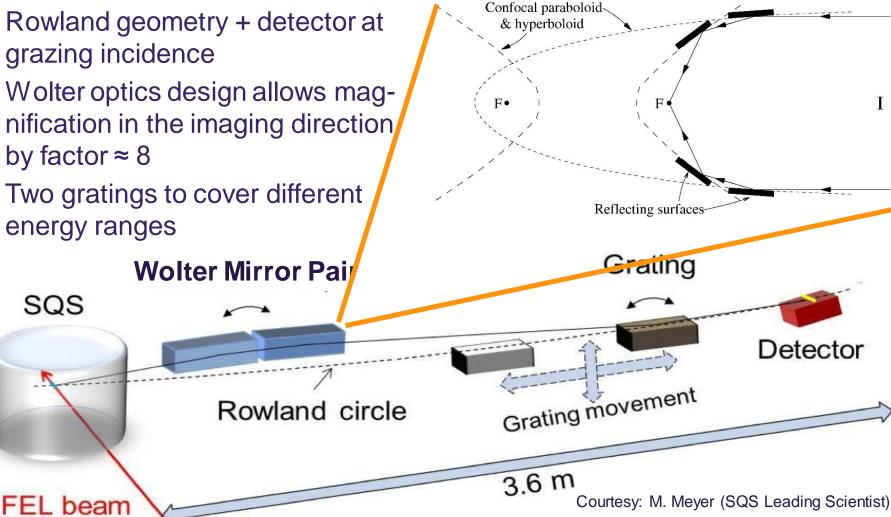
**Wolter I Optics** 

#### European **XFEL** SQS: Soft X-ray Single Shot Spectrometer

### **Experiment Setup**



- Wolter optics design allows magnification in the imaging direction by factor  $\approx 8$
- Two gratings to cover different energy ranges



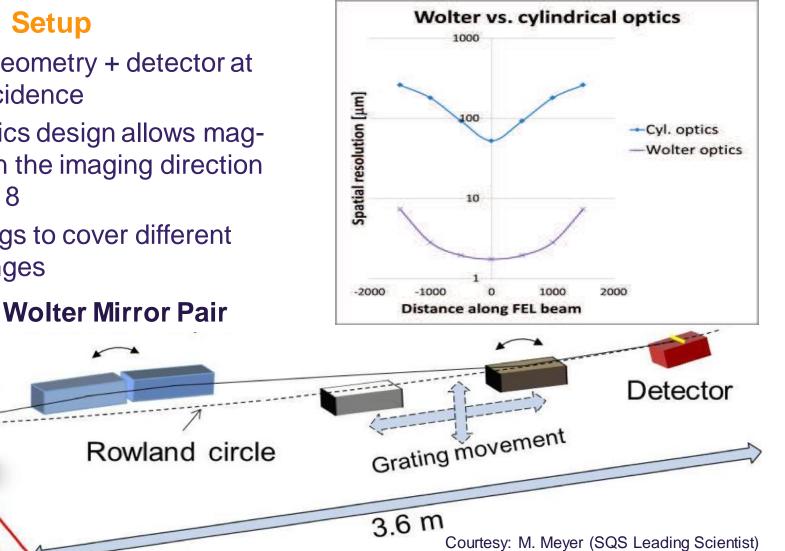
SQS



#### European XFEL SQS: Soft X-ray Single Shot Spectrometer

### **Experiment Setup**

- Rowland geometry + detector at grazing incidence
- Wolter optics design allows magnification in the imaging direction by factor  $\approx 8$
- Two gratings to cover different energy ranges



SQS

FEL beam

# **XFEL** MCP Detector with DLD Readout

# MCP Detector with Delay Line Readout

4.5 MHz compatible Si based imaging detectors with pixel sizes < 100 μm are not available.

Use micro-channel plate to convert single photons to 10<sup>3</sup>–10<sup>4</sup> electrons

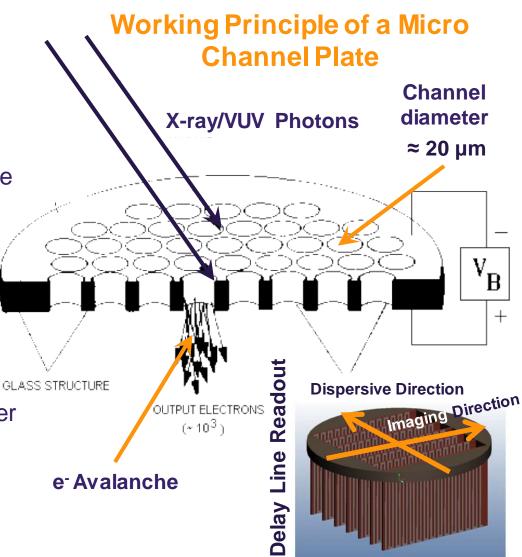
#### Advantage

- Fast detector for single shot imaging
- Reasonable sensitivity
- Good spatial resolution

### Limitations

- Dead time of a single pore is much longer than  $\mu s$
- $\rightarrow$  use Wolter optics to distribute signal
- Spatial resolution





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